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IN THE U.S. PATENT AND TRADEMARK OFFICE

Applicant:	Lain-Jong Li, et al.	§	Docket No.:	TS01-195CC
		§		(24061.579)
Serial No.:	10/823,149	§		
		§	Examiner:	Dung Anh Le
Filed:	April 13, 2004	§		
		§	Art Unit:	2818
For:	Composite Etching Stop	§		
	in Semiconductor Process	§	Conf. No.:	2818
	Integration	§		

PRELIMINARY AMENDMENT

Commissioner for Patents
Mail Stop: Amendments
P.O. Box 1450
Alexandria, VA 22313-1450

Dear Sir:

Prior to the initial examination, please amend the above-identified application as follows:

Amendments to the Claims begin on page 2 of this paper.

Remarks/Arguments begin on page 6 of this paper.